

GEANT4 BEGINNERS COURSE

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Physics in Geant4: Particles, processes, cuts and models

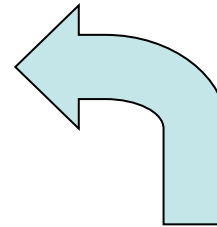
Geant 4 tutorial course



Introduction

Mandatory user classes in a Geant4:

- **G4VUserPrimaryGeneratorAction**
- **G4VUserDetectorConstruction**
- **G4VUserPhysicsList**



*Particles, physics processes, and cut-off parameters to be used in the simulation must be defined in the **G4VUserPhysicsList** class*

Why a physics list?

- “*Physics is physics* – shouldn't Geant4 provide, as a default, a complete set of physics that everyone can use?”
- **NO:**
 - Software can only capture Physics through a modelling
 - No unique Physics modelling
 - Very much the case for hadronic physics
 - But also the electromagnetic physics
 - Existing models still evolve and new models are created
 - Some models are more suited to some energy ranges
 - Medical applications not interested in multi-GeV physics in general
 - HEP experiments not interested in effects due to atomic shell structure
 - computation speed is an issue
 - a user may want a less-detailed, but faster approximation

Why a physics list?

- For this reason Geant4 takes an atomistic, rather than an integral approach to physics
 - provide many physics independent components (processes)
 - user selects these components in custom physics lists
- This physics environment is built by the user in a flexible way:
 - picking up the particles he/she wants
 - picking up the physics to assign to each particle
- User must have a good understanding of the physics required
 - omission of particles or physics could cause errors or poor simulation

User may also use some provided “ready-to-use” physics list

G4VUserPhysicsList: required methods

ConstructParticle() :

- choose the particles you need in your simulation, define all of them here

ConstructProcess() :

- for each particle, assign all the physics processes relevant to your simulation
 - What's a process ?
 - a class that defines how a particle should interact with matter, or decays
 - » it's where the physics is!

SetCuts() :

- Set range cuts for secondary particle production
 - What's a range cut ?
 - a threshold on particle production
 - » Secondary Particles unable to travel at least the range cut value are not produced

Particles: basic concepts

There are three levels of class to describe particles in Geant4:

- **G4ParticleDefinition**
 - defines a particle
 - aggregates information to characterize a particle's properties (name, mass, spin, etc...)
- **G4VDynamicParticle**
 - describes a particle interacting with materials
 - aggregates information to describe the dynamic of particles (energy, momentum, polarization, etc...)
- **G4VTrack**
 - describes a particle travelling in space and time
 - includes all the information for tracking in a detector simulation (position, step, current volume, track ID, parent ID, etc...)

Definition of a particle

Geant4 provides the **G4ParticleDefinition** definition class to represent a large number of elementary particles and nuclei, organized in six major categories:

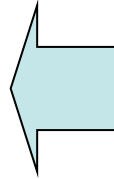
lepton, meson, baryon, boson, shortlived and ion

- Each particle is represented by its own class, for example **G4Electron**, which is derived from `G4ParticleDefinition`
- Properties characterizing individual particles are “read only” and can not be changed directly

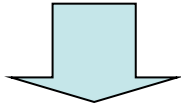
*User must define **all particles** type which are used in the application: not only **primary particles** but also all other particles which may appear as **secondaries** generated by the used physics processes*

Constructing particles

Due to the large number of particles can be necessary to define, this method sometimes can be not so comfortable

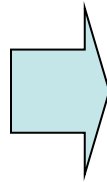


```
void  
MyPhysicsList::ConstructParticle()  
{  
    G4Electron::ElectronDefinition();  
    G4Proton::ProtonDefinition();  
    G4Neutron::NeutronDefinition();  
    G4Gamma::GammaDefinition();  
    ....  
}
```



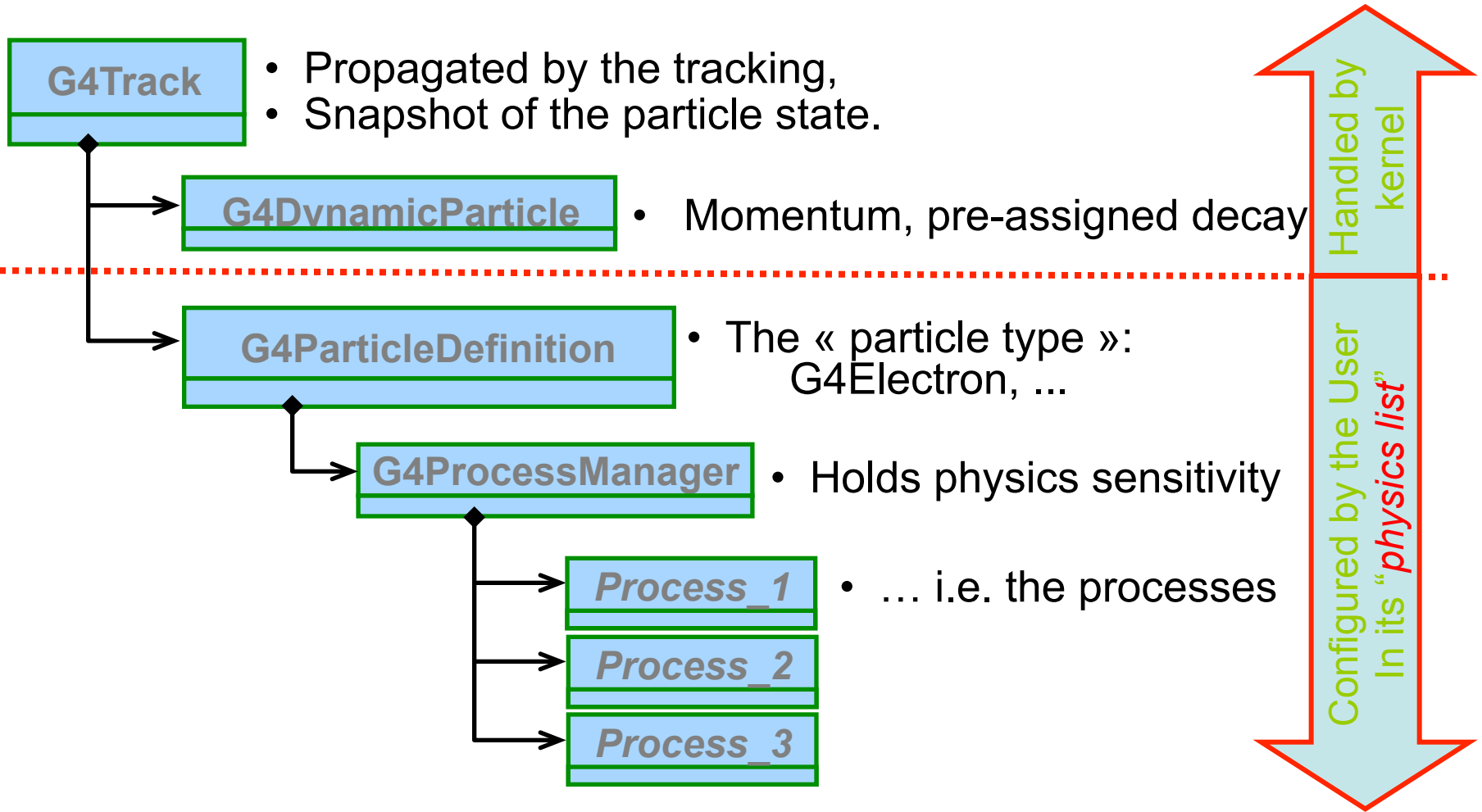
It is possible to define **all** the particles belonging to a **Geant4 category**:

- **G4LeptonConstructor**
- **G4MesonConstructor**
- **G4BaryonConstructor**
- **G4BosonConstructor**
- **G4ShortlivedConstructor**
- **G4IonConstructor**



```
void  
MyPhysicsList::ConstructBaryons()  
{  
    // Construct all baryons  
    G4BaryonConstructor pConstructor;  
    pConstructor.ConstructParticle();  
}
```


From particles to processes



Processes

Physics processes describe how particles interact with materials

Geant4 provides seven major categories of processes:

- Electromagnetic
- Hadronic
- Decay
- Optical
- Photolepton_hadron
- Parameterization
- Transportation

A process does two things:

- 1) decides when and where an interaction will occur
 - methodS: **GetPhysicalInteractionLength** → *limit the step*
 - this requires a cross section
 - for the transportation process, the distance to the nearest object
- 2) generates the final state of the interaction (changes momentum, generates secondaries, etc.)
 - methodS: **DoIt**
 - this requires a model of the physics

G4VProcess class

Physics processes are derived from the **G4VProcess** base class

- Abstract class defining the common interface of **all processes** in Geant4:
 - Used by all physics processes (also by the transportation, etc...)
 - Defined in **source/processes/management**
- Define **three kinds of actions**:

- **AtRest** actions:

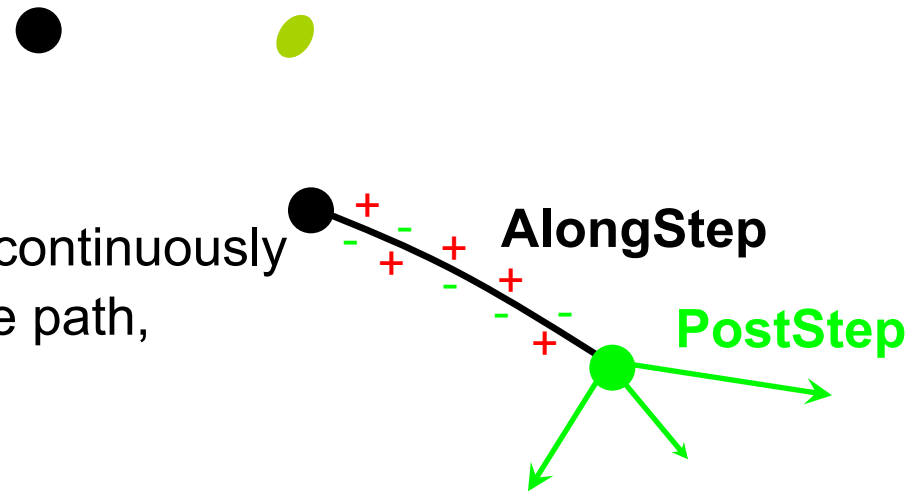
- Decay, e^+ annihilation ...

- **AlongStep** actions:

- To describe (inter)actions, continuously occurring along the particle path, like ionisation;

- **PostStep** actions:

- To describe point-like (inter)actions, like decay in flight, hadronic interactions ...



A process can implement a combination of them (decay = AtRest + PostStep)

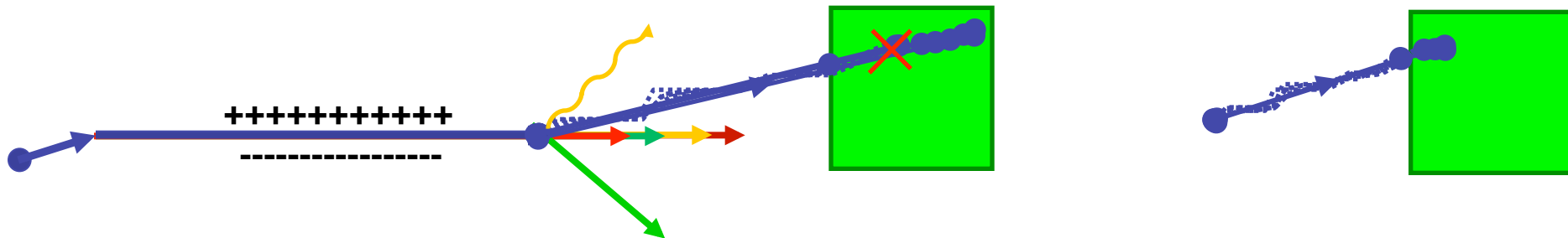
Example processes

- Discrete process: **Compton Scattering, hadronic inelastic, ...**
 - step determined by cross section, interaction at end of step
 - PostStepGPIL(), PostStepDolt()
 - Continuous process: **Cerenkov effect**
 - photons created along step, roughly proportional to step length
 - AlongStepGPIL(), AlongStepDolt()
 - At rest process: **mu- capture at rest**
 - interaction at rest
 - AtRestGPIL(), AtRestDolt()
- pure*
- Rest + discrete: **e+ annihilation, decay, ...**
 - both in flight and at rest
 - Continuous + discrete: **ionization**
 - energy loss is continuous
 - knock-on electrons (δ -ray) are discrete
- combined*

Handling multiple processes

- STAGE 1: a particle is shot and “transported”
- STAGE 2: all processes associated to the particle propose a geometrical step length (depends on process cross-section)
- STAGE 3: The process proposing the shortest step “wins” and the particle is moved to destination (if shorter than “Safety”)
- STAGE 4: All processes “along the step” are executed (e.g. ionization)
- STAGE 5: “post step” phase of the process that limited the step is executed
New tracks are “pushed” to the stack
- STAGE 6: If $E_{\text{kin}}=0$ all “at rest” processes are executed; if particle is stable the track is killed. Else:
- STAGE 7: A new step starts and sequence repeats...

Processes return a “true path length”. The multiple scattering “virtually folds up” this true path length into a shorter “geometrical” path length. Transportation process can limit the step to geometrical boundaries.

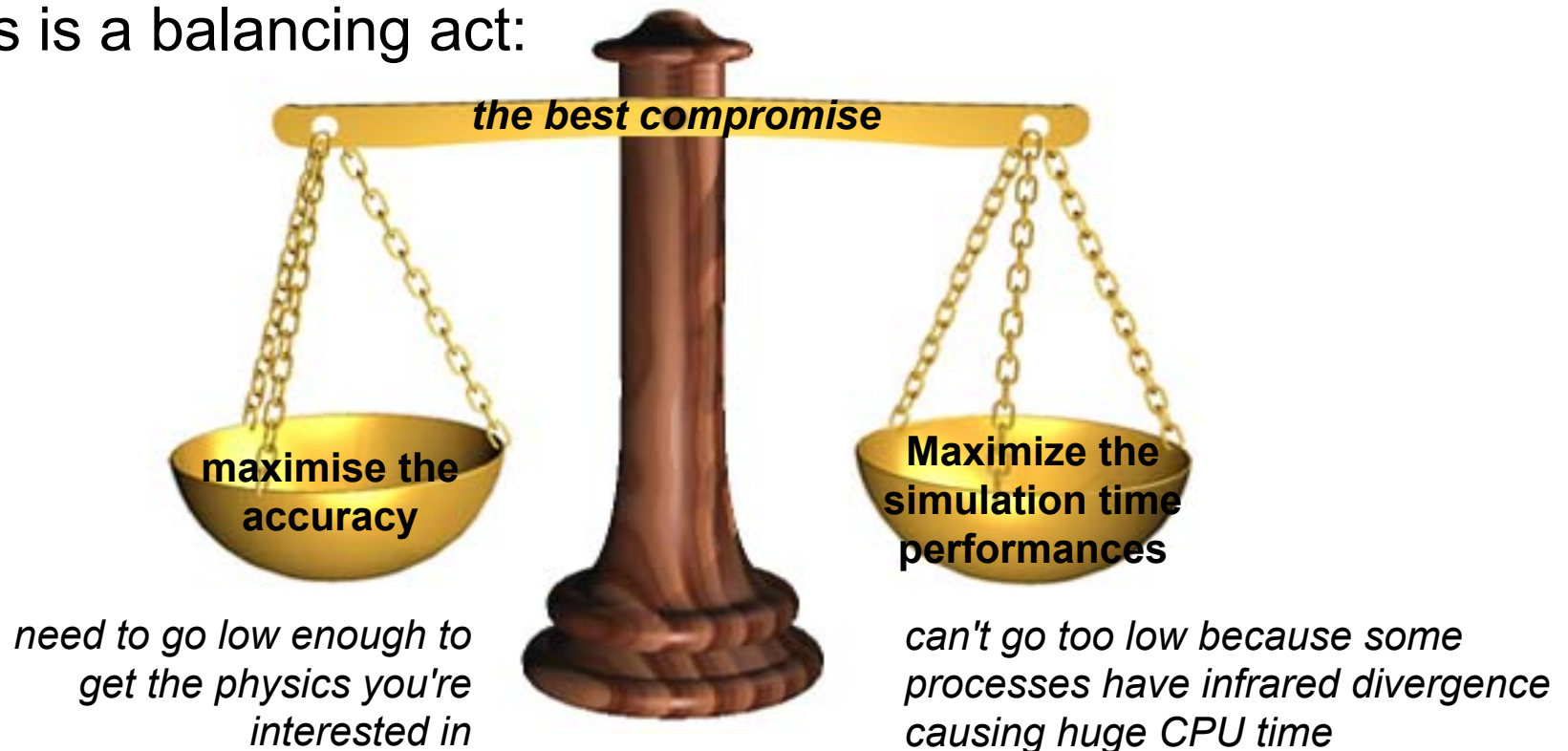


Production thresholds: cut

Each simulation developer must answer the question:
how low can I go?

- should I produce (and track) every secondary or should I consider thresholds?

This is a balancing act:



Production thresholds: cut

- The **traditional Monte Carlo** solution is to impose an absolute cutoff in energy:
 - particles are stopped when this energy is reached
 - remaining energy is dumped at that point
- But, such a cut may cause **imprecise stopping location** and localization of energy deposition
- There is also a **particle dependence**
 - range of 10 keV p in Si is different from range of 10 keV e⁻ in Si
- And a **material dependence**
 - suppose you have a detector made of alternating sheets of Pb and plastic scintillator
 - if the cutoff is OK for Pb, it will likely be wrong for the scintillator which does the actual energy deposition measurement

Production thresholds: cut

- In Geant4 there are no tracking cuts
 - particles are tracked down to a zero range/kinetic energy
- Only **production cuts** exist
 - i.e. cuts allowing a particle to be born or not
 - Applied to: ***gamma, electron, positron, proton***
- *Why are production cuts needed ?*

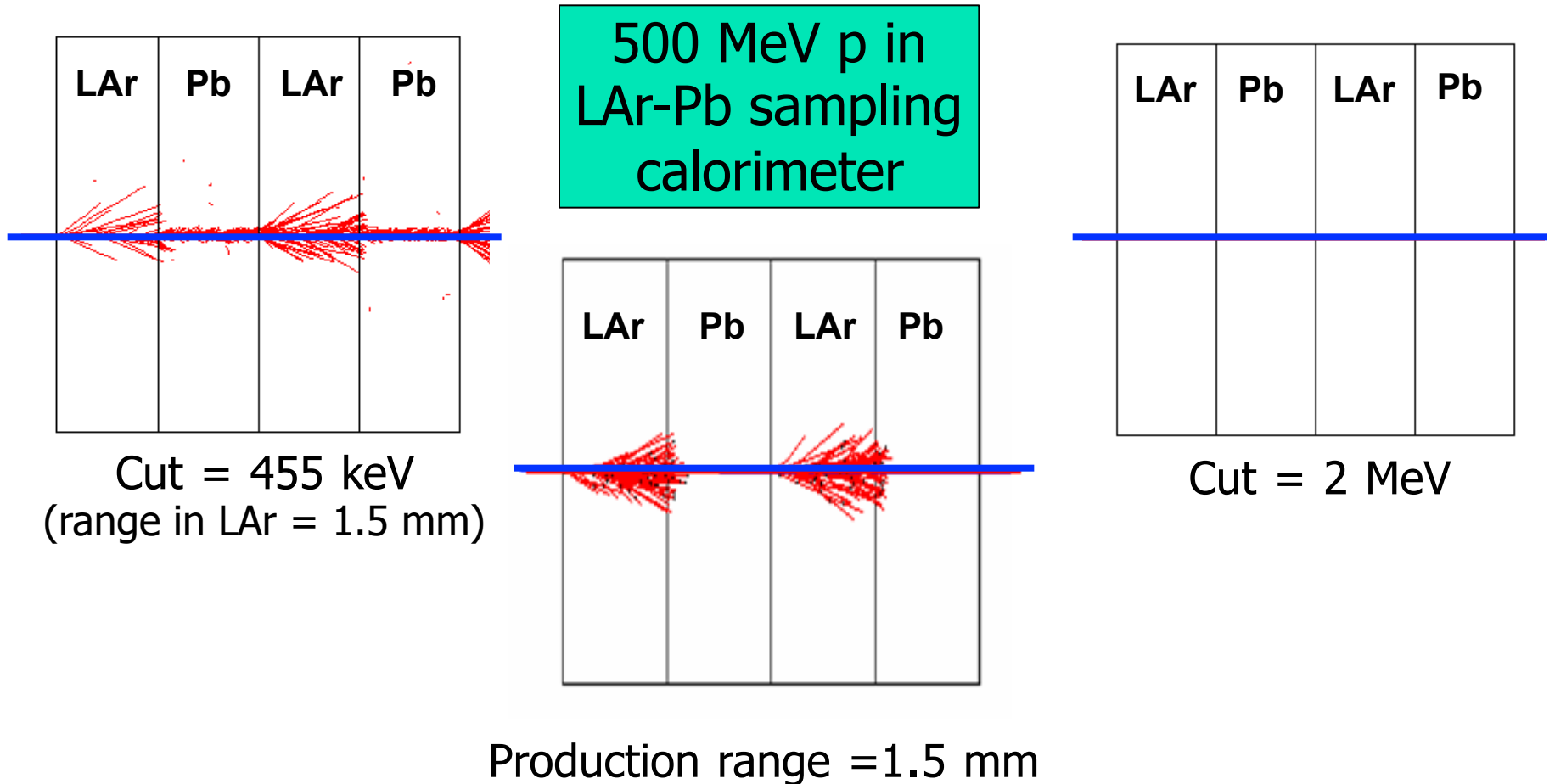
Some electromagnetic processes involve infrared divergences

- this leads to a huge number of smaller and smaller energy photons/ electrons (such as in Bremsstrahlung, d-ray production)
- production cuts limit this production to particles above the threshold
- the remaining, divergent part is treated as a continuous effect (i.e. AlongStep action) → Energy balance is preserved

Production thresholds: cut

- Geant4 solution: impose a “range” **production threshold**
 - this threshold is a **distance**, not an energy
 - default = 1 mm
- Only one production threshold cut is uniformly set
- Production threshold is internally converted to an energy threshold, **depending on particle type and material**
- When primary no longer has enough energy to produce secondaries which travel at least 1mm, two things happen:
 - discrete energy loss stops (no more secondaries produced)
 - the primary is tracked down to zero energy using continuous energy loss
 - Stopping location is therefore correct

Production thresholds: cut



Threshold in range: 1.5 mm



455 keV electron energy in liquid Ar
2 MeV electron energy in Pb

Cuts per region

- A complex detector may be composed by many different sub-detectors:
 - finely segmented volumes
 - very sensitive materials
 - large, undivided volumes
 - inert materials
- The same cuts may not be appropriate for all of these
 - User can define regions (logical volume envelopes) and assign different cuts for each region
- Warning: this feature is for users who are
 - simulating complex detectors
 - experienced at simulating EM showers in matter
 - Good practice: cross check with uniform set of cuts to avoid biases

Thanks for your attention